PHOTODIODES FOR HIGH-PERFORMANCE APPLICATIONS ■

AVALANCHE PHOTODIODES FOR ANALYTICAL APPLICATIONS Avalanche Photodiodes Si APD Arrays



Avalanche Photodiodes – Si APD Arrays

Applications

- Spectroscopy
- Particle detection
- Spot tracking and alignment systems
- Adaptive optics
- Lidar

Features and Benefits

- High quantum efficiency
- Hermetically sealed packages
- Monolithic chip with minimal dead space between elements
- Specific tailored wavelength response
- RoHS compliant

Product Description

C30927 series of quadrant Si Avalanche Photodiode and the C30985E multi-element APD array utilize the double-diffused "reach-through" structure. This structure provides ultra high sensitivity at 400-1000 nm.

The C30927 quadrant structure has a common avalanche junction, with separation of the quadrants achieved by segmentation of the light entry p+ surface opposite the junction. With this design, there is no dead space between the elements and therefore no loss of response at boresight.

The C30927EH-01, -02 and -03 are optimized for use at wavelengths of 1060, 900, and 800 nm respectively. Each device type will provide high responsivity and excellent performance when operated within about $50 \, \mathrm{nm}$ of the specified wavelength.

The C30985E is a 25 element monolithic linear APD array having a high inter-electrode resistance with a 75 μ m dead space between the elements. Packages have a common ground and bias with a separate lead for each element output.

Product Table

Avalanche Photodiodes - Si APD Arrays Number Photo Sensitive Dark Current Spectral Noise Capacitance @ 100 KHz NEP Part Number of Elements Diameter Responsivity Current Response Time per Element Unit fW /√Hz) mm mm nΑ pA/√Hz C30927EH-01 1.5 25 275 - 425 4 15(@ 1060 nm) 0.5 3 33(@ 1060 nm) C30927EH-02 4 1.5 62(@ 900 nm) 25 0.5 3 16(@ 900 nm) 275-425 C30927EH-03 1.5 25 275-425 4 55(@ 800 nm) 0.5 3 9(@ 800 nm) 0.3 31(@ 900 nm) C30985E 25 0.1 0.5 3(@ 900 nm) 250-425



